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Novel and highly productive process for robust layers on flexible materials

The Fraunhofer Institute for Organic Electronics, Electron Beam and Plasma Technology FEP, a provider of research and development services for all coating technologies, will be presenting research advances in the area of high-rate coating at the 2018 FLEX conference in Monterey, USA from February 12–15, 2018.

Wearables, arched displays and buildings facades increasingly require bendable, flexible surfaces with tailored functionality and properties. These coating functionalities include the reduction of gas permeation, protection against chemicals, radiation, and mechanical contact as well as conductive coatings and layers with specific optical properties. Surfaces are equipped with thin functional layers to achieve these properties and functionalities. Increasing productivity and efficiency of these coating processes is an important focus of our applications-oriented research.

One of these deposition technologies is plasma-enhanced chemical vapor deposition. Fraunhofer FEP is active in the field of improved PECVD processes for high productivity and efficient application in roll-to-roll coating equipment. These processes provide large-area, cost-effective coating of flexible substrate material. In contrast to conventional processes, Fraunhofer FEP employs magnetrons and hollow-cathodes as plasma sources.

Michiel Top, Project Manager in the Flat and Flexible Products division at Fraunhofer FEP, is pleased with the results: "The development of our hollow-cathode PECVD process has provided us with a versatile tool for the deposition of silicon-containing plasma polymer layers on flexible substrates. The process not only allows us to scale up to web-widths up to four meters but can also be directly combined with other deposition techniques like sputtering and evaporation in a single facility."

Dynamic coating rates of up to 3000 nanometers for 1 meter per minute web-speed have been attained for plasma polymer layers. This figure is about five to ten times higher compared to conventional processes like microwave PECVD. Plasma polymer layers deposited upon functional layers offer good protection against chemical attack (acids and salts) and against mechanical loading such as found in winding equipment

when materials undergo additional roll-to-roll processing. It was shown that the water vapour transmittance of an inorganic barrier coating can be reduced by up to 50% by in-line deposition of a polymer-like protective layer.

This process allows for the deposition of tailored layer's properties (composition, hardness, and refractive index) without losing the possibility to tune the dynamic coating rate within prescribed limits. In combination with sputter processing for example, this facilitates in-line deposition of multiple layers in a single pass for optical interference coating systems, saving process steps and therefore money.

The researchers see the next goal to be further improvement of both the process and the layers for various application scenarios, such as in flexible electronic components, through close cooperation with partners from industry such as machine builders and end-users. This way, transfer of the process towards the production level is targeted in the near future.

Fraunhofer FEP at 2018 FLEX:**Exhibition Booth: No. 5002****Presentations:**Wednesday, February 14, 2018: Session 12: FE Tools & Methods

12.2 B, 04:20 p.m., Michiel Top:

Application of high-rate PECVD for improved mechanical stability of Roll-to-roll manufactured flexible organic electronics<http://s.fhg.de/VUF>Thursday February 15, 2018: Session 17: Substrates

17.2 B, 10:40 a.m., Dr. Manuela Junghänel:

Refinement of transparent conductive films on flexible glass by in-line flash-lamp annealing

<http://s.fhg.de/Syt>



An array of hollow-cathodes has already been successfully employed for coating widths of up to 2.85 meters in an industrial application

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Picture in printable resolution: www.fep.fraunhofer.de/press



Film with a transparent barrier coat

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The **Fraunhofer Institute for Organic Electronics, Electron Beam and Plasma Technology FEP** works on innovative solutions in the fields of vacuum coating, surface treatment as well as organic semiconductors. The core competences electron beam technology, sputtering and plasma-activated deposition, high-rate PECVD as well as technologies for the organic electronics and IC/system design provide a basis for these activities. Thus, Fraunhofer FEP offers a wide range of possibilities for research, development and pilot production, especially for the processing, sterilization, structuring and refining of surfaces as well as OLED microdisplays, organic and inorganic sensors, optical filters and flexible OLED lighting. Our aim is to seize the innovation potential of the electron beam, plasma technology and organic electronics for new production processes and devices and to make it available for our customers.